

## Suppression of carbon deposition in CO<sub>2</sub>-reforming of methane on metal sulfide catalysts

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The catalytic performance of metal sulfides of Mo and W was studied for the CO<sub>2</sub>-reforming of methane by comparing with that of Ni/SiO<sub>2</sub>. The sulfide catalysts have lower activity than the Ni/SiO<sub>2</sub> catalyst for this reaction, however, no deactivation due to carbon deposition was observed on the sulfide catalysts. The activity for direct decomposition of CH<sub>4</sub> was much smaller on the sulfides than on supported Ni. The rate equation suggested that, during steady-state reaction, the surface was abundant in adsorbed CO<sub>2</sub> on sulfides, by which direct decomposition of CH<sub>4</sub> should be retarded in addition to their lower activity for this reaction.

**Keywords:** carbon deposition; CO<sub>2</sub>-reforming; methane; metal sulfide; supported Ni

### 1. Introduction

The reduction of CO<sub>2</sub> with CH<sub>4</sub> has become a fashionable reaction because the reacting gases are both contributing significantly to the greenhouse effect [1,2]. The CO<sub>2</sub>-reforming of CH<sub>4</sub> is an appropriate reaction, because this reaction can convert these two harmful gases to useful syngas. Supported Ni is known as a typical catalyst for this reaction. During steady-state reaction, carbon deposition often accompanies the reaction, by which a catalyst is deactivated and continuous flow of reactant gases is disturbed. Therefore, a high performance catalyst must be developed, on which carbon deposition is suppressed completely.

In a conventional catalyst system, carbon deposition has been controlled by the presence of excess amount of carbon dioxide [4,5] or by the addition of alkaline metal salts to supported Ni catalysts [6,7]. Partial poisoning of supported Ni catalyst with sulfur compounds, SPARG process [8], is reported as another way to suppress carbon deposition.

It was reported that the activity for the methanation of CO significantly decreased with time on Ni and Fe, however, not so significantly on MoS<sub>2</sub> [9]. The metal sulfide catalyst may also exhibit high performance for the CO<sub>2</sub>-reforming of CH<sub>4</sub> without accompanying carbon deposition, although the origin of carbon

deposition may be different between these two reactions. In this paper, the catalytic performance of MoS<sub>2</sub> and WS<sub>2</sub> was studied for CO<sub>2</sub>-reforming of CH<sub>4</sub> by comparing with that of a supported Ni catalyst.

## 2. Experimental

MoS<sub>2</sub> and WS<sub>2</sub> catalysts were prepared by decomposing the respective precursors ((NH<sub>4</sub>)<sub>2</sub>MoS<sub>4</sub> and (NH<sub>4</sub>)<sub>2</sub>WS<sub>4</sub>; both from Aldrich) in a stream of hydrogen. XRD patterns of the prepared catalysts showed broad diffraction peaks of molybdenum and/or tungsten disulfide. For comparison, the Ni/SiO<sub>2</sub> catalyst (metal loading, 20 wt%) was prepared by impregnating SiO<sub>2</sub> with an aqueous solution of Ni(NO<sub>3</sub>)<sub>2</sub>, followed by drying and subsequent calcination at 773 K for 3 h. Before use, it was reduced with flowing hydrogen.

The CO<sub>2</sub>-reforming of CH<sub>4</sub> was carried out by using a conventional flow type microreactor. After reducing a catalyst in a stream of hydrogen (40 ml min<sup>-1</sup>) at 723 K for 3 h, helium (40 ml min<sup>-1</sup>) was flowed over the catalyst at 723 K for 30 min. Then an equimolar mixture of CH<sub>4</sub> and CO<sub>2</sub> (28 ml min<sup>-1</sup>) was introduced on the catalyst. The catalyst weight was 5.1 mg, 305.1 mg, and 359.0 mg for Ni/SiO<sub>2</sub>, MoS<sub>2</sub>, and WS<sub>2</sub>, respectively. The reaction was carried out under the condition of a differential reactor. Effluent gases were analyzed by gas chromatography.

Dependence of reaction time was investigated at 873 K for 6 h. After reducing a catalyst (catalyst weight, 93.5 mg for Ni/SiO<sub>2</sub> and 500 mg for MoS<sub>2</sub>) with flowing hydrogen at 873 K for 3 h, helium was flowed over the catalyst at 873 K for 30 min. Then, an equimolar mixture of CH<sub>4</sub> and CO<sub>2</sub> (total flow rate, 28 ml min<sup>-1</sup> and 60 ml min<sup>-1</sup> for MoS<sub>2</sub> and Ni/SiO<sub>2</sub>, respectively) was introduced onto the catalyst.

Dependence of reaction rate on partial pressures was investigated under the condition of a differential reactor. After reducing a catalyst with flowing hydrogen at 973 K for 3 h followed by purging with helium at 973 K for 30 min, a mixture of CH<sub>4</sub>, CO<sub>2</sub>, and helium (total flow rate, 54 ml min<sup>-1</sup>) was introduced onto the catalyst. The catalyst weight was 5.1 mg for Ni/SiO<sub>2</sub>, 305.1 mg for MoS<sub>2</sub>, and 280.3 mg for WS<sub>2</sub>.

The amount of CO adsorbed on the catalyst was measured by a conventional pulse technique at 298 K in a flow of helium as a carrier gas: 41.0 μmol g<sup>-1</sup> for Ni/SiO<sub>2</sub>, 15.0 μmol g<sup>-1</sup> for MoS<sub>2</sub>, and 38.6 μmol g<sup>-1</sup> for WS<sub>2</sub>.

The rate of carbon deposition on the catalyst was investigated by using thermal gravimetric analysis. After the reduction of a catalyst with hydrogen followed by purging with helium at 773 K, CH<sub>4</sub> (40 ml min<sup>-1</sup>) was flowed over the catalyst and the catalyst weight was continuously measured. The catalyst weight was 25.5 mg for Ni/SiO<sub>2</sub>, 16.5 mg for MoS<sub>2</sub>, and 50.7 mg for WS<sub>2</sub>.

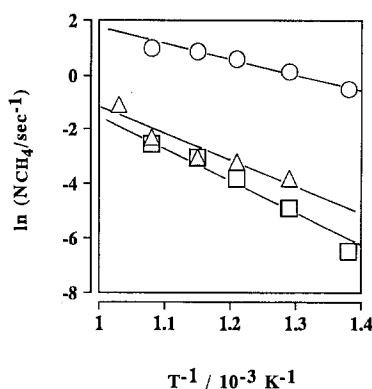


Fig. 1. Arrhenius plots for  $\text{CH}_4$ - $\text{CO}_2$  reaction on  $\text{Ni}/\text{SiO}_2$  (○),  $\text{MoS}_2$  (△), and  $\text{WS}_2$  (□) using the continuous flow technique.

### 3. Results and discussion

Fig. 1 shows the rates of methane conversion on the sulfide catalysts and the  $\text{Ni}/\text{SiO}_2$  catalyst in the initial period of time. The rates can be compared with each other on the basis of turnover frequency ( $N_{\text{CH}_4}/\text{s}^{-1}$ ). As shown, the sulfide catalysts exhibited lower activity than the  $\text{Ni}/\text{SiO}_2$  catalyst for this reaction. Of the sulfide catalysts,  $\text{MoS}_2$  showed a little higher activity than  $\text{WS}_2$ , while the apparent activation energy seemed to be a little larger on  $\text{WS}_2$  than on  $\text{MoS}_2$ .

Fig. 2 shows the decay of catalyst activity for  $\text{CO}_2$ -reforming of  $\text{CH}_4$ . Due to carbon deposition, supported Ni lost its activity significantly. On  $\text{MoS}_2$ , on the other hand, no deactivation was observed, although the activity was smaller than on supported Ni. Fig. 3 summarizes the dependence of the reaction rate on partial pressures. The rate equation was expressed by

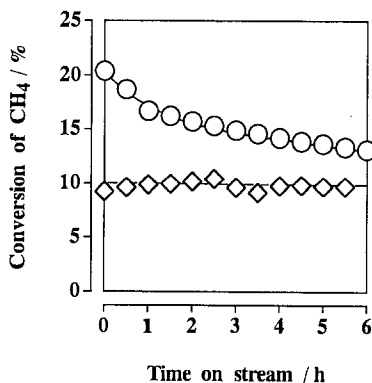


Fig. 2. Decay of catalyst activity for the  $\text{CO}_2$ -reforming of  $\text{CH}_4$  on  $\text{Ni}/\text{SiO}_2$  (○) and  $\text{MoS}_2$  (◇). Reaction temperature = 873 K.  $W/F = 0.582 \text{ g h mol}^{-1}$  for  $\text{Ni}/\text{SiO}_2$  and  $6.67 \text{ g h mol}^{-1}$  for  $\text{MoS}_2$ .

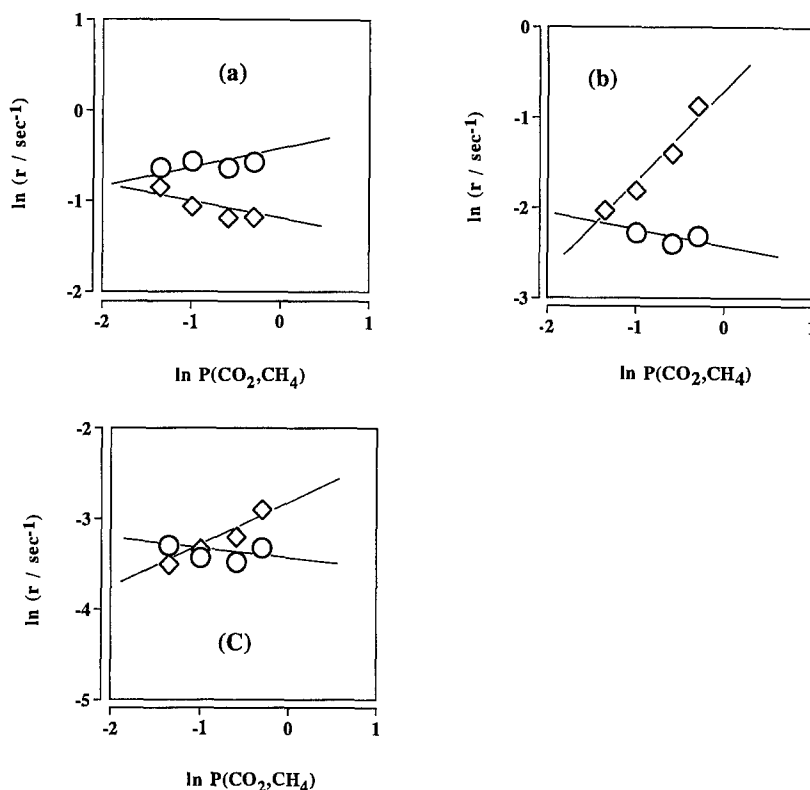


Fig. 3. Dependence of reaction rate on partial pressures for the  $\text{CO}_2$ -reforming of  $\text{CH}_4$  on  $\text{Ni/SiO}_2$  (a),  $\text{MoS}_2$  (b), and  $\text{WS}_2$  (c) at 973 K.  $\log r$  vs.  $\log P_{\text{CO}_2}$  ( $\circ$ ),  $\log r$  vs.  $\log P_{\text{CH}_4}$  ( $\diamond$ ).

$$r_1 = k_1 P_{\text{CH}_4}^{0.54 \text{ to } 0.76} P_{\text{CO}_2}^{-0.09 \text{ to } -0.10} \quad \text{for sulfide catalysts,}$$

$$r_2 = k_2 P_{\text{CH}_4}^{-0.30} P_{\text{CO}_2}^{0.16} \quad \text{for supported Ni catalyst,}$$

where  $r_i$  and  $k_i$  are the reaction rate and the rate constant, respectively, and  $P_j$  is the partial pressure of reactant gas. The reaction order observed with respect to partial pressure suggested that, under steady-state reaction conditions, the catalyst surface was abundant in adsorbed  $\text{CO}_2$  on sulfides, while in adsorbed  $\text{CH}_4$  on supported Ni. Since carbon deposition is caused by the decomposition of  $\text{CH}_4$ , covering the sulfide surface with adsorbed  $\text{CO}_2$  should yield a favorable condition for avoiding  $\text{CH}_4$  decomposition, which results in no deactivation as shown in fig. 2. Fig. 4 shows the activity for  $\text{CH}_4$  decomposition in the absence of  $\text{CO}_2$ . Sulfide catalysts were much less active than supported Ni, which should be another cause for the absence of deactivation during steady-state  $\text{CO}_2$ -reforming of  $\text{CH}_4$ .

Our preliminary experiment showed that alkaline metal salts added to supported Ni changed the reaction order with respect to  $\text{CH}_4$  partial pressure from zeroth or negative to positive value and with respect to  $\text{CO}_2$  partial pressure from positive to

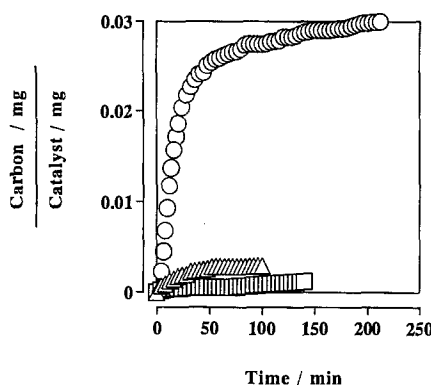


Fig. 4. Decomposition of  $\text{CH}_4$  in the absence of  $\text{CO}_2$  on  $\text{Ni/SiO}_2$  (○),  $\text{MoS}_2$  (△), and  $\text{WS}_2$  (□) at 773 K.

zeroth or negative value [10]. The addition of alkaline salts also decreased the activity of supported Ni for the direct decomposition of  $\text{CH}_4$ . These observations were very similar to the present findings on sulfide catalysts, which may allow us to speculate that metal sulfides of Mo and W play the same part as alkali-promoted Ni catalysts. The precise characterization of the sulfide catalysts is now in progress.

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